

Physics

Investigation of the Role of Negatively Charged Impurity Centers in Formation of Inverse Distribution of Photoelectrons. The Kinetics Equation and Formation of the Inverse Distribution Function

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ABSTRACT. The active medium with the inverse charge carrier population is known to form the basis of up-to-date semiconductor masers and lasers. This population can be created by various actions including electron generation and heating towards the conductivity region by means of electromagnetic radiation (photoheating). The objective of our study was to find the conditions for formation of regions of hot photoelectron distribution when their lifetime is controlled by trapping either negatively or positively charged impurity centers for different energy relaxation mechanisms, both quasi-elastic and strongly inelastic. © 2010 Bull. Georg. Natl. Acad. Sci.

Key words: inverse population, photoelectron distribution.

Let us consider a semiconductor at low temperatures ($T \ll \varepsilon_i$, ε_i is the ionization energy) where the external monochromatic radiation excites electrons with the ε_0 “throw up” energy in the conductivity region. This energy is much higher than the equilibrium. Later, the excited electrons recombine, pre-scattering part of their initial energy by acoustic lattice oscillations. Our task is to establish the type of the electron distribution function under the above-mentioned conditions when their lifetime is controlled by trapping by repulsive (negatively charged) impurity centers.

At high energies photoelectron “throw up” when the quasielasticity condition is violated and the distribution is far from equilibrium, one can use the Fokker-Planck equation. In this case spontaneous radiation is proved to play a main role in the flow and the term

describing the departure of electrons on a lower energy state is predominant. The integral has the form [1,2]:

$$J(\varepsilon) = \frac{\partial}{\partial \varepsilon} \left[\frac{g(\varepsilon)\varepsilon}{\tau_{ak}(\varepsilon)} f(\varepsilon) \right], \quad (1)$$

where $f(\varepsilon)$ is the charge carrier distribution function, $\tau_{ak}(\varepsilon)$ is the acoustic phonon emission time:

$$\tau_{ak}(\varepsilon) = \frac{2\sqrt{2}E_i^2 m^{5/2}}{\pi \hbar^4 \rho} \varepsilon^{-1/2}. \quad (2)$$

Proceeding from the above, at high “throw up” energy in the stationary condition the kinetic equation will have the form:

$$\frac{\partial}{\partial \varepsilon} \left[\frac{g(\varepsilon)\varepsilon}{\tau_{ak}(\varepsilon)} f(\varepsilon) \right] - \frac{f(\varepsilon)g(\varepsilon)}{\tau_c(\varepsilon)} + I\delta(\varepsilon - \varepsilon_0) = 0. \quad (3)$$

$f(\varepsilon)g(\varepsilon)/\tau_c(\varepsilon)$ is the term describing the number of recombined electrons per unit time, $I\delta(\varepsilon - \varepsilon_0)$ is the photoelectron generation velocity with the “throw up” energy ε_0 ; it is described by the δ functions, I is the number of “born” photoelectrons per unit time, $\tau_c(\varepsilon) = (N\sigma v)^{-1}$ is the photoelectron lifetime with respect to trapping by repulsive centers with the concentration N .

The accurate solution of equation (3) in different energy regions has different forms [1]. The studies have shown that in the $\varepsilon > \varepsilon_0$ region $f(\varepsilon)$ is a decreasing energy function and at high ε it passes into the Boltzmann distribution. And in the $\varepsilon < \varepsilon_0$ region,

$$f(\varepsilon) = f_1(\varepsilon) = \frac{CI\tau_{ak}(\varepsilon)}{g(\varepsilon)\varepsilon} \exp \left[-\int_{\varepsilon}^{\varepsilon_0} \frac{\tau_{ak}(\varepsilon)}{\tau_c(\varepsilon)\varepsilon} d\varepsilon \right], \quad (4)$$

C is found from the $f(\varepsilon)$ normalization condition.

In the general case, for any trapping mechanism and energy relaxation way, $f(\varepsilon)$ has the extreme point (ε_m) if the condition $\tau_{ak}(\varepsilon)/\tau_c(\varepsilon) = 2$ is fulfilled. When the probability of extra energy losses is higher than that of free electron trapping, hot electrons first are thermolyzed and only afterwards are trapped by different impurity centers. In this case they do not form a non-equilibrium distribution function, since they have time to come into equilibrium with the lattice. If the trapping probability is higher than that of energy relaxation, this distribution is established and it can be inverse. Electrons have no time to be re-distributed on low energy levels. Assuming that the energy relaxation takes place during acoustic phonon scattering, the inversion condition for the distribution function takes the form [2]: $\tau_c(\varepsilon) < \tau_{ak}(\varepsilon)$.

In the first part of the present work a wide range of materials creating negatively charged trapping centers in Ge has been studied. The conclusion was made: only during trapping by Au^{\equiv} and Pt^{\equiv} centers the hot photoelectron lifetime ($\tau_c(\varepsilon)$) can be varied within a sufficiently wide range. Accordingly, to find inverse areas in the distribution function, in the energy region $\varepsilon < \varepsilon_0$,

the function $f_1(\varepsilon)$ was studied for Au^{\equiv} and Pt^{\equiv} impurities at different values of ε_0 and N .

It was obtained that at high N and ε values, depending on $f_1(\varepsilon)$, there is a maximum point and $f_1(\varepsilon)$ up to this point is an increasing energy function. Hence, the states in this region are inversely populated.

At high “throw up” energies electrons start to emit intensively acoustic phonons, descending energetically to the value ε_3 , below which $\tau_c(\varepsilon) < \tau_{ak}(\varepsilon)$. This suggests that electrons born with the energy $\varepsilon_0 > \varepsilon_3$, first accumulate in the ε_3 region and only afterwards are trapped by repulsive centers. Under condition $\varepsilon_0 \gg \varepsilon_3$, the descent time does not depend on ε_0 and it is determined by the equation:

$$\tau(\varepsilon_3) = \left(\frac{1}{\sqrt{\varepsilon_3}} - \frac{1}{\sqrt{\varepsilon_1}} \right) \sqrt{2ml_0} = 2 \left(1 - \sqrt{\frac{\varepsilon_3}{\varepsilon_0}} \right) \tau_{ak,\varepsilon}(\varepsilon_3) \quad (5)$$

The value ε_3 is defined by the N values and does not depend on ε_0 . With increasing N , ε_3 shifts toward higher values and thereby the inversion area broadens.

In the inverse part of the distribution function the energy values are such that optical phonon radiation is possible. Therefore, we have in this region:

$$\tau_{\varepsilon}^{-1} = \tau_{ak,\varepsilon}^{-1} + \tau_{op,\varepsilon}^{-1} \quad (6)$$

where $\tau_{op,\varepsilon}$ is the energy relaxation time with optical phonon radiation [3]:

$$\tau_{op,\varepsilon} = \frac{\sqrt{2}\pi\hbar^4 \rho S^2}{(m\hbar\omega_0)^{3/2} E_{1,op}^2} \left(\frac{\varepsilon}{\hbar\omega_0} - 1 \right)^{-1/2} \quad (7)$$

where $E_{1,op}$ is the deformation potential coefficient under optical scattering.

The results of the theoretical estimations carried out are given in Figs. 1 and 2. It is clear from the figures that the optical phonon radiation only narrows the energy area where $f_1(\varepsilon)$ is inverse.

To summarize, we can state that the inversion in the $f(\varepsilon)$ dependence of photoelectrons can be observed in Pt^{\equiv} on repulsive centers at $N_{Pt} > 10^{16} \text{ cm}^{-3}$, and for Au^{\equiv} with reasonable N values, the inversion will be weak in the narrow energy region.

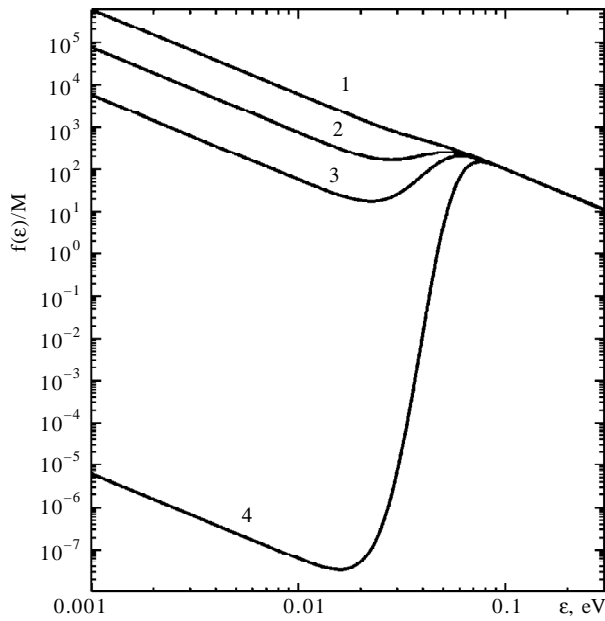


Fig. 1. Distribution function in the Pt-doped Ge samples at different values of N_{Pt} .

- 1. - $N_{Pt}=10^{15} \text{ cm}^{-3}$; 2. - $N_{Pt}=5 \cdot 10^{15} \text{ cm}^{-3}$;
- 3. - $N_{Pt}=10^{16} \text{ cm}^{-3}$; 4. - $N_{Pt}=5 \cdot 10^{16} \text{ cm}^{-3}$;

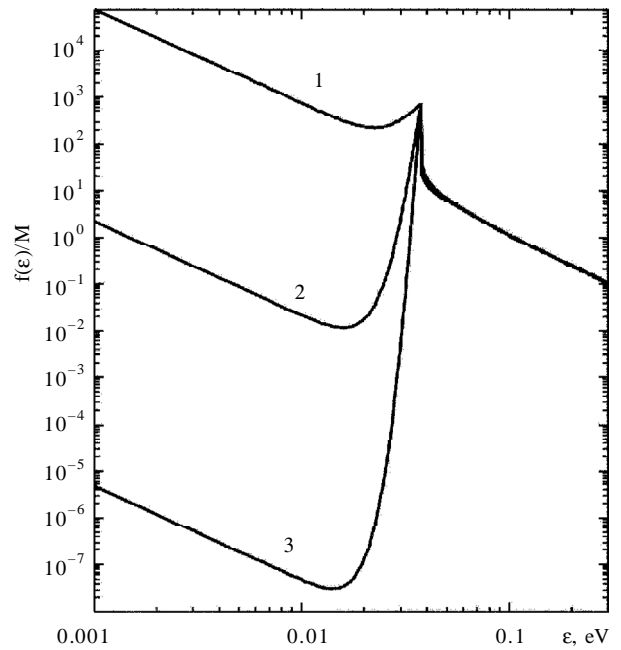


Fig. 2. Distribution function in the Pt-doped Ge samples at different values of N_{Pt} (with allowance for the process of scattering by optical phonons).

- 1. - $N_{Pt}=10^{16} \text{ cm}^{-3}$; 2. - $N_{Pt}=5 \cdot 10^{16} \text{ cm}^{-3}$; 3. - $N_{Pt}=10^{17} \text{ cm}^{-3}$.

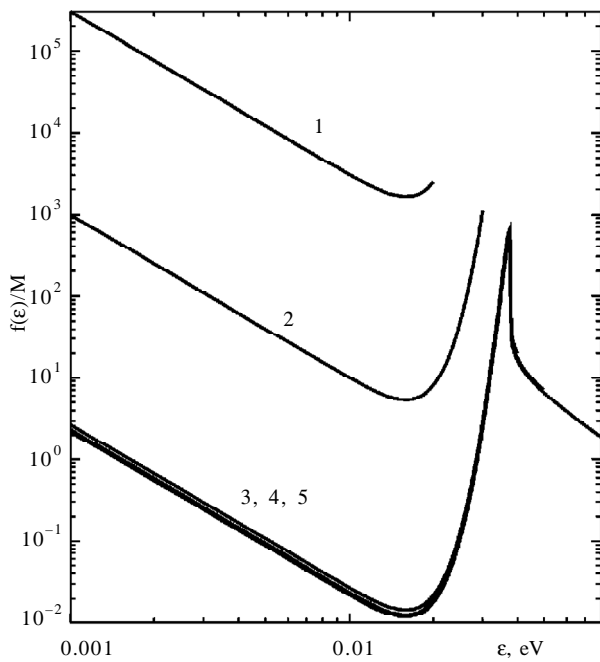


Fig. 3. Distribution function in the Pt-doped Ge samples at different values of N_{Pt} ($N_{Pt}=5 \cdot 10^{16} \text{ cm}^{-3}$) at different ϵ_0 values.

- 1. - $\epsilon_0=0,02 \text{ eV}$; 2. - $\epsilon_0=0,03 \text{ eV}$; 3. - $\epsilon_0=0,05 \text{ eV}$;
- 4. - $\epsilon_0=0,08 \text{ eV}$; 5. - $\epsilon_0=0,1 \text{ eV}$.

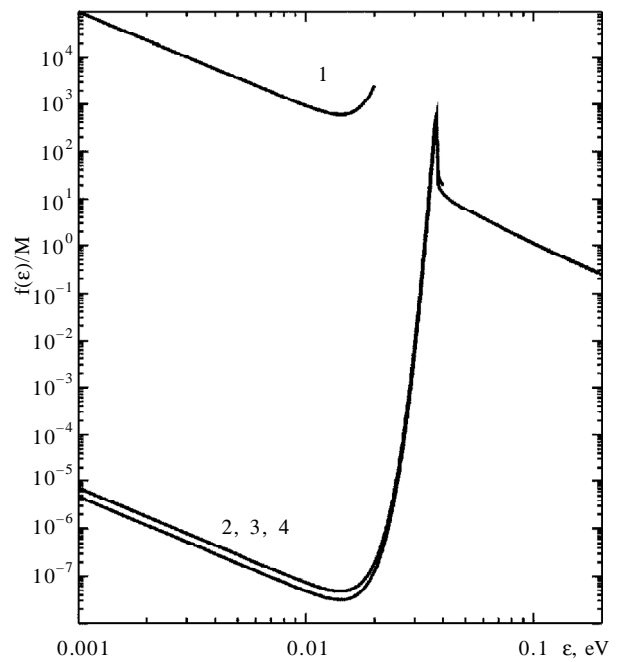


Fig. 4. Distribution function in the Pt-doped Ge samples at different values of N_{Pt} ($N_{Pt}=5 \cdot 10^{17} \text{ cm}^{-3}$) at different ϵ_0 values.

- 1. - $\epsilon_0=0,02 \text{ eV}$; 2. - $\epsilon_0=0,08 \text{ eV}$; 3. - $\epsilon_0=0,1 \text{ eV}$;
- 4. - $\epsilon_0=0,15 \text{ eV}$.

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ფიზიკა

უარყოფითად დამუხტული მინარევული ცენტრების როლის გამოკვლევა ფოტოელექტრონების ინვერსიული განაწილების ფორმირებაში; კინეტიკის განტოლება და ინვერსიული განაწილების ფუნქციის ფორმირება

ე. ხიზანიშვილი*, ზ. ქაჩლიშვილი*, მ. ხიზანიშვილი*, მ. გიგაური*

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(წარმოდგენილია აკადემიკოს თ. სანაძის მიერ)

მოცემულ ნაშრომში ჩვენი გამოკვლევების მიზანს წარმოადგენდა ცხელი ფოტოელექტრონების ინვერსიული განაწილების ფორმირების პირობების დადგენა, როდესაც მათი სიციცხლის ხანგრძლივობა კონტროლდება უარყოფითად დამუხტულ მინარევულ ცენტრებზე ჩაჭვრით, ენერჯიის რელაქსაციის სხვადასხვა მექანიზმებისას; როგორც კვაზიდრეკადი, ასევე ძლიერად არადრეკადი.

თორიულმა გამოთვლებმა გვიჩვენეს, რომ Ge-ში მხოლოდ Au^- და Pt^- ცენტრებზე ჩაჭვრისას შეიძლება ცხელი ფოტოელექტრონების სიციცხლის დროის ვარირება ენერჯიის ფართო დიაპაზონში. განაწილების ფუნქციის ინვერსიულობა Ge-ში Pt^- -ის ($N_{Pt} > 10^{16} \text{ სმ}^{-3}$ -სას) განმზიდავ ცენტრებზე გაბნვისას შეიძლება დაშვებულ იქნეს ენერჯიის საკმაოდ ფართო არეებში. ხოლო Au^- -სათვის, N-ის დასაშვებ მნიშვნელობებზე, ინვერსია იქნება სუსტი ენერჯიის ვიწრო არეებში.

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